

CANON ANELVA Products

*Creating the future
with vacuum technology*

*Vacuum is a state of space having sub-atmospheric pressure.
Ultra-high vacuum that enables nano level micro fabrication is naturally
available only in outer space at the altitude of 300 km or above.
This ultra-high vacuum is where CANON ANELVA's expertise lies.*

CANON ANELVA contributes to the development of better society through supplying manufacturing equipment based on ultra-high vacuum technology for semiconductors, electronic parts and FPD.

Etching for MTJ



NC8000

Sputtering for Memory Wire



IC7500

Sputtering for 200mm Interconnects

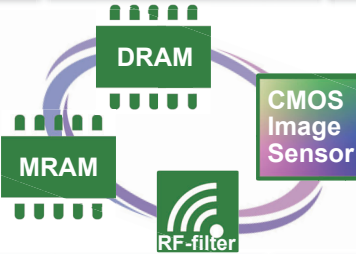


IC1060

Sputtering for MTJ



NC7900



Sputtering for HKMG and CMOS Image sensor



FC7100

Sputtering for Mask blanks (Large Panel)



EL35xx

Sputtering for SAW filter



EC7400

Headquarters (Kanagawa pref.)



Fuji Factory (Yamanashi pref.)

